	Application No.	Applicant(s)
Notice of Allowability	10/091,485	MITTELSTADT ET AL.
	Examiner	Art Unit
	Dah-Wei D. Yuan	1745
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (Inherewith (or previously mailed), a Notice of Allowance (PTOL-85) of NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGORY OF THE O	or other appropriate communi	is application. If not included
1. X This communication is responsive to <u>9/28/04</u> .		
2. ⊠ The allowed claim(s) is/are <u>1-10,47,48 and 50</u> .		
3. The drawings filed on <u>07 March 2002</u> are accepted by the E	xaminer.	
4. ☐ Acknowledgment is made of a claim for foreign priority und a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have be	peen received.	
2. Copies of the priority documents have b	peen received in Application N	lo
 Copies of the certified copies of the priority docu International Bureau (PCT Rule 17.2(a)). 	ments have been received in	this national stage application from the
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONME THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	this communication to file a r NT of this application.	eply complying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be submitted INFORMAL PATENT APPLICATION (PTO-152) which gives	ed. Note the attached EXAMII reason(s) why the oath or de	NER'S AMENDMENT or NOTICE OF Claration is deficient.
6. CORRECTED DRAWINGS (as "replacement sheets") must be	pe submitted.	
(a) ☐ including changes required by the Notice of Draftsperson	n's Patent Drawing Review (F	TO-948) attached
1) ☐ hereto or 2) ☐ to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's A Paper No./Mail Date	mendment / Comment or in t	he Office action of
Identifying indicia such as the application number (see 37 CFR 1.84 each sheet. Replacement sheet(s) should be labeled as such in the	(c)) should be written on the di header according to 37 CFR 1.	rawings in the front (not the back) of 121(d).
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT FO 	of BIOLOGICAL MATERIA	N. manusatta and a sure a sure
Attachment(s)		
1. Notice of References Cited (PTO-892)	Notice of Inform	al Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summ	ary (PTO-413),
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No./Mail Date	Paper No./Mail 7.	ndment/Comment
 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	8. ⊠ Examiner's State 9. □ Other	ement of Reasons for Allowance

Application/Control Number: 10/091,485

Art Unit: 1745

ION EXCHANGE SYSTEM STRUCTURE WITH A MICROTEXTURED SURFACE, METHOD OF MANUFACTURE, AND METHOD OF USE THEREOF

Examiner: Yuan

S.N. 10/091,485

Art Unit: 1745

November 18, 2004

Continued Examination Under 37 CFR 1.114

- 1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on August 24, 2004 has been entered. Claims 11-19,49 were cancelled. Claims 1,50 were amended.
- 2. The text of those sections of Title 35, U.S.C. code not included in this action can be found in the prior Office Action issued on May 28, 2004.

Claim Rejections

3. The claim rejections under 35 U.S.C. 102(e) as anticipated by Ruhl et al. on claims 1-10,47-50 are withdrawn because the independent claim 1 has been amended. The claim rejections under 35 U.S.C. 102(e) as anticipated by Shastri et al. on claims 1-3,8,9,47-50 are withdrawn because the independent claim 1 has been amended.

Application/Control Number: 10/091,485 Page 2 of 3

Art Unit: 1745

Reasons for Allowance

4. Claims 1-10,47,48,50 are allowed. The invention of independent claim 1 recites a substrate for an ion-exchange electrode structure comprising an exterior surface wherein at least a potion of the exterior surface is irradiated by a laser radiation, wherein the reactive surface area has two-scales of roughness, a first scale of roughness at least three orders of magnitude different than a second scale of roughness. The closest prior arts of record, Ruhl et al. and Shastri et al., do not teach or suggest aforementioned features on the exterior surface of the substrate for an ion-exchange electrode structure. In addition, the references do not disclose any special laser ablation technique that would result Iin the two-scale roughness as recited in the claim.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dah-Wei D. Yuan whose telephone number is (571) 272-1295. The examiner can normally be reached on Monday-Friday (8:00-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Patrick J. Ryan, can be reached on (571) 272-1292. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you

Art Unit: 1745

have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Dah-Wei D. Yuan November 18, 2004 Delive: /